(FILE 'HOME' ENTERED AT 22:53:03 ON 08 JUL 2004)

	FILE	'REGI	STRY'	' ENTERED AT 22:53:09 ON 08 JUL 2004						
L1		STRUCTURE UPLOADED STRUCTURE UPLOADED STRUCTURE UPLOADED								
L2										
L3										
L4		129	S L1	1 FULL						
L5		80	S L2	2 FULL						
L6		528	S L3	3 FULL						
	FILE	'CAPL	US' E	ENTERED AT 22:54:25 ON 08 JUL 2004						
L7		34909	S PH	HOTORESIST OR RESIST COMPOSITION						
L8		4	S L4	AND L7						
Ь9		2	S L5	5 AND L7						
L10		4	S L6	S AND L7						
L11		2	S L8	NOT L9						
L12		0	S L9	O NOT L8						
=> S	=> s 110 not 18									
L13	L13 0 L10 NOT L8									

```
ANSWER 1 OF 4 CAPLUS COPYRIGHT 2004 ACS on STN
ΑN
     2002:955415 CAPLUS
DN
     138:47300
    Nitrogen-containing basic compound, resist material, and method of
IN
    Hatakeyama, Jun; Watanabe, Takeshi; Nagata, Takashi; Maeda, Kazuki; Nishi,
     Tsunehiro
PA
     Shin-Etsu Chemical Industry Co., Ltd., Japan
     Jpn. Kokai Tokkyo Koho, 30 pp.
     CODEN: JKXXAF
DT
     Patent
     Japanese
FAN.CNT 1
     PATENT NO.
                    KIND DATE
                                         APPLICATION NO. DATE
     -----
                     ----
                                         ______
    JP 2002363148 A2 20021218
                                         JP 2001-164044 20010531
PRAI JP 2001-164044
                         20010531
os
    MARPAT 138:47300
    The N-containing basic compound is represented by (R2)bN(R1COOCRpRqRr)a (R1 =
AB
    C1-4 alkylene; R2 = H, C1-20 alkyl; Rp, Rq, Rr = C1-20 hydrocarbon which
     may form ring; a = 1, 2, 3; b = 0, 1, 2; and a + b = 3). The resist
     material containing the basic compound is also claimed. The patterning process
     using a high energy ray ≤300 nm or an electron beam is also
     claimed. An addition of the basic compound in the resist material provided a
    broader focus margin and a high contrast.
    478407-85-1P 478407-88-4P
IT
    RL: SPN (Synthetic preparation); TEM (Technical or engineered material
    use); PREP (Preparation); USES (Uses)
        (nitrogen-containing basic compound for resist material)
RN
    478407-85-1 CAPLUS
    \beta-Alanine, N,N-bis(2-methoxyethyl)-, 1,1-dimethylethyl ester (9CI)
CN
     (CA INDEX NAME)
                  CH_2-CH_2-OMe
t-BuO-C-CH_2-CH_2-N-CH_2-CH_2-OMe
RN
    478407-88-4 CAPLUS
CN
     β-Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 1,1-dimethylethyl ester
     (9CI) (CA INDEX NAME)
                 CH2-CH2-OAC
t-BuO-C-CH2-CH2-N-CH2-CH2-OAC
L8
```

- ANSWER 2 OF 4 CAPLUS COPYRIGHT 2004 ACS on STN
- AN 2002:831831 CAPLUS
- DN 137:325160
- TI Preparation of novel tertiary amine compounds having an ester structure as additives for chemical amplification resists
- Watanabe, Takeru; Hasegawa, Koji; Kinsho, Takeshi; Hatakeyama, Jun IN
- PA Shin-Etsu Chemical Co., Ltd., Japan
- SO Eur. Pat. Appl., 31 pp.

CODEN: EPXXDW

DT Patent

English LA

FAN.CNT 1

PATENT NO. KIND DATE APPLICATION NO. DATE

```
20021030
                                           EP 2002-252827
PI
     EP 1253138
                     A2
                                                            20020423
     EP 1253138
                      A3
                            20030924
            AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, SI, LT, LV, FI, RO, MK, CY, AL, TR
     US 2002193622
                      A1
                            20021219
                                           US 2002-127120
                                                            20020422
                       A2
                            20030115
                                           JP 2002-120468
                                                            20020423
     JP 2003012621
PRAI JP 2001-123927
                       Α
                            20010423
     MARPAT 137:325160
AB
     The invention provides novel and useful ester group-containing tertiary amine
     compds. (R1OCH2CH2)nN(CH2CH2CO2R2)3-n [n is 1 or 2; R1, R2 = (cyclo)alkyl
     groups which may contain an ether, carbonyl or carbonyloxy group] which,
     when used as additives in chemical amplification photolithog., can yield
     photoresists having a high resolution and an excellent focus margin. Thus, a
     mixture of 10.5 g each Et acrylate and diethanolamine was allowed to stand
     20 h at 20-30 °C, 25.6 g triethylamine, 100 mg 4-
     dimethylaminopyridine, 100 g THF, and 22.4 g of acetic anhydride were
     added and the mixture stirred for 10 h to afford 95 %
     (AcOCH2CH2) NCH2CH2CO2Et. The photoresists prepared by adding the ester
     group-containing tertiary amine compds. of the invention have a much wider
     focus margin, as compared with conventional photoresists.
TΤ
     350684-62-7P 350684-66-1P 350684-69-4P
     350684-73-0P 350684-75-2P 350684-79-6P
     350684-80-9P 350684-81-0P 473713-58-5P
     473713-59-6P 473713-60-9P 473713-61-0P
     473713-62-1P 473713-64-3P 473713-65-4P
     473713-67-6P 473713-68-7P 473713-69-8P
     473713-70-1P 473713-71-2P 473713-72-3P
     473713-73-4P 473713-74-5P 473713-75-6P
     473713-76-7P 473713-77-8P 473713-78-9P
     473713-79-0P 473713-80-3P 473713-81-4P
     473713-82-5P 473713-83-6P 473713-84-7P
     473713-85-8P 473713-86-9P 473713-87-0P
     473713-89-2P 473713-90-5P 473713-91-6P
     473713-92-7P 473713-93-8P 473713-94-9P
     473713-95-0P 473713-96-1P 473713-97-2P
     473713-98-3P 473713-99-4P 473714-00-0P
     473714-01-1P 473714-02-2P 473714-25-9P
     RL: MOA (Modifier or additive use); SPN (Synthetic preparation); PREP
     (Preparation); USES (Uses)
        (preparation of acrylate-(di)ethanolamine adducts as additives for chemical
        amplification resists)
RN
     350684-62-7 CAPLUS
CN
     \beta-Alanine, N,N-bis[2-(acetyloxy)ethyl]-, ethyl ester (9CI) (CA INDEX
     NAME)
    Aco-CH2-CH2
ACO-CH2-CH2-N-CH2-CH2-C-OEt
     350684-66-1 CAPLUS
RN
CN
     \beta-Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-methoxyethyl ester (9CI)
     (CA INDEX NAME)
    Aco-CH2-CH2
Aco-CH_2-CH_2-N-CH_2-CH_2-C-O-CH_2-CH_2-OMe
RN
     350684-69-4 CAPLUS
CN
     β-Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-(acetyloxy)ethyl ester
```

RN 350684-73-0 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-oxopropyl ester (9CI) (CA INDEX NAME)

RN 350684-75-2 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, (tetrahydro-2-furanyl)methyl ester (9CI) (CA INDEX NAME)

RN 350684-79-6 CAPLUS

CN β -Alanine, N,N-bis[2-(formyloxy)ethyl]-, 4-(formyloxy)butyl ester (9CI) (CA INDEX NAME)

RN 350684-80-9 CAPLUS

CN β -Alanine, N,N-bis[2-(formyloxy)ethyl]-, 2-(formyloxy)ethyl ester (9CI) (CA INDEX NAME)

RN 350684-81-0 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, methyl ester (9CI) (CA INDEX NAME)

RN 473713-58-5 CAPLUS

CN β-Alanine, N,N-bis[2-(acetyloxy)ethyl]-, propyl ester (9CI) (CA INDEX NAME)

RN 473713-59-6 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 1-methylethyl ester (9CI) (CA INDEX NAME)

 $i-PrO-C-CH_2-CH_2-N-CH_2-CH_2-OAC$

RN 473713-60-9 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, butyl ester (9CI) (CA INDEX NAME)

RN 473713-61-0 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, pentyl ester (9CI) (CA INDEX NAME)

RN 473713-62-1 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, hexyl ester (9CI) (CA INDEX NAME)

RN 473713-64-3 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, decyl ester (9CI) (CA INDEX NAME)

RN 473713-65-4 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, pentadecyl ester (9CI) (CA INDEX NAME)

$$\begin{array}{c|c} & \text{O} & \text{CH}_2\text{--}\text{CH}_2\text{--}\text{OAc} \\ || & | & | \\ \text{Me--} (\text{CH}_2)_{14}\text{--}\text{O--}\text{C--}\text{CH}_2\text{--}\text{CH}_2\text{--}\text{N--}\text{CH}_2\text{--}\text{CH}_2\text{--}\text{OAc} \\ \end{array}$$

RN 473713-67-6 CAPLUS

CN β-Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-(acetyloxy)-2-oxoethyl
ester (9CI) (CA INDEX NAME)

RN 473713-68-7 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-(2-methoxyethoxy)ethyl ester (9CI) (CA INDEX NAME)

RN 473713-69-8 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-ethoxyethyl ester (9CI) (CA INDEX NAME)

RN 473713-70-1 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 4-(acetyloxy)butyl ester (9CI) (CA INDEX NAME)

RN 473713-71-2 CAPLUS

RN 473713-72-3 CAPLUS

CN β -Alanine, N,N-bis[2-[[(acetyloxy)acetyl]oxy]ethyl]-, ethyl ester (9CI) (CA INDEX NAME)

RN 473713-73-4 CAPLUS

CN β -Alanine, N,N-bis[2-[(methoxyacetyl)oxy]ethyl]-, methyl ester (9CI) (CA INDEX NAME)

RN 473713-74-5 CAPLUS

CN β -Alanine, N,N-bis[2-[(methoxyacetyl)oxy]ethyl]-, ethyl ester (9CI) (CA INDEX NAME)

RN 473713-75-6 CAPLUS

CN 2,8,10-Trioxa-5-azadodecanoic acid, 5-(3-methoxy-3-oxopropyl)-11,11-dimethyl-9-oxo-, 1,1-dimethylethyl ester (9CI) (CA INDEX NAME)

RN 473713-76-7 CAPLUS

CN 2,8,10-Trioxa-5-azadodecanoic acid, 5-(3-ethoxy-3-oxopropyl)-11,11-dimethyl-9-oxo-, 1,1-dimethylethyl ester (9CI) (CA INDEX NAME)

RN 473713-77-8 CAPLUS CN β -Alanine, N,N-bis[2-(1-oxopropoxy)ethyl]-, methyl ester (9CI) (CA INDEX NAME)

RN 473713-78-9 CAPLUS

CN β -Alanine, N,N-bis[2-(1-oxopropoxy)ethyl]-, ethyl ester (9CI) (CA INDEX NAME)

$$\begin{array}{c} {\rm O} \\ {\rm CH_2-CH_2-O-C-Et} \\ {\rm ||} \\ {\rm Et-C-O-CH_2-CH_2-N-CH_2-CH_2-C-OEt} \\ {\rm ||} \\ {\rm |$$

RN 473713-79-0 CAPLUS

CN β-Alanine, N,N-bis[2-(formyloxy)ethyl]-, methyl ester (9CI) (CA INDEX NAME)

RN 473713-80-3 CAPLUS

CN β-Alanine, N,N-bis[2-(formyloxy)ethyl]-, ethyl ester (9CI) (CA INDEX NAME)

RN 473713-81-4 CAPLUS

CN β-Alanine, N,N-bis[2-(2,2-dimethyl-1-oxopropoxy)ethyl]-, methyl ester (9CI) (CA INDEX NAME)

RN 473713-82-5 CAPLUS

CN β -Alanine, N,N-bis[2-(2,2-dimethyl-1-oxopropoxy)ethyl]-, ethyl ester

RN 473713-83-6 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, ethyl ester (9CI) (CA INDEX NAME)

$$\begin{array}{c|c} {\tt O} & {\tt CH_2-CH_2-OMe} \\ || & | \\ {\tt EtO-C-CH_2-CH_2-N-CH_2-CH_2-OMe} \end{array}$$

RN 473713-84-7 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, propyl ester (9CI) (CA INDEX NAME)

$$\begin{array}{c|c} \text{O} & \text{CH}_2\text{--}\text{CH}_2\text{--}\text{OMe} \\ || & | \\ \text{n-PrO-C--}\text{CH}_2\text{--}\text{CH}_2\text{--}\text{N--}\text{CH}_2\text{--}\text{CH}_2\text{--}\text{OMe} \end{array}$$

RN 473713-85-8 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, butyl ester (9CI) (CA INDEX NAME)

$$\begin{array}{c|c} \mathsf{O} & \mathsf{CH}_2-\mathsf{CH}_2-\mathsf{OMe} \\ || & | \\ \mathsf{n}-\mathsf{BuO}-\mathsf{C}-\mathsf{CH}_2-\mathsf{CH}_2-\mathsf{N}-\mathsf{CH}_2-\mathsf{CH}_2-\mathsf{OMe} \end{array}$$

RN 473713-86-9 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, pentyl ester (9CI) (CA INDEX NAME)

RN 473713-87-0 CAPLUS

CN β-Alanine, N,N-bis(2-methoxyethyl)-, hexyl ester (9CI) (CA INDEX NAME)

RN 473713-89-2 CAPLUS

CN β-Alanine, N,N-bis(2-methoxyethyl)-, 2-ethylhexyl ester (9CI) (CA

INDEX NAME)

RN 473713-90-5 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, 2-methoxyethyl ester (9CI) (CA INDEX NAME)

RN 473713-91-6 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, 2-ethoxyethyl ester (9CI) (CA INDEX NAME)

$$\begin{array}{c|c} & \text{O} & \text{CH}_2-\text{CH}_2-\text{OMe} \\ \parallel & \parallel & \parallel \\ \text{EtO-CH}_2-\text{CH}_2-\text{O-C-CH}_2-\text{CH}_2-\text{N-CH}_2-\text{CH}_2-\text{OMe} \\ \end{array}$$

RN 473713-92-7 CAPLUS

CN β-Alanine, N,N-bis(2-methoxyethyl)-, 2-propoxyethyl ester (9CI) (CA INDEX NAME)

RN 473713-93-8 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, 2-(1-methylethoxy)ethyl ester (9CI) (CA INDEX NAME)

RN 473713-94-9 CAPLUS

CN β-Alanine, N,N-bis(2-methoxyethyl)-, 2-butoxyethyl ester (9CI) (CA INDEX NAME)

RN 473713-95-0 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, 2-(2-methoxyethoxy)ethyl ester (9CI) (CA INDEX NAME)

RN 473713-96-1 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, (tetrahydro-2-furanyl)methyl ester (9CI) (CA INDEX NAME)

RN 473713-97-2 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, 2-oxopropyl ester (9CI) (CA INDEX NAME)

RN 473713-98-3 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, 2-(acetyloxy)ethyl ester (9CI) (CA INDEX NAME)

RN 473713-99-4 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, 4-(acetyloxy)butyl ester (9CI) (CA INDEX NAME)

RN 473714-00-0 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, 2-[[(acetyloxy)acetyl]oxy]ethyl ester (9CI) (CA INDEX NAME)

RN 473714-01-1 CAPLUS

CN β-Alanine, N,N-bis(2-methoxyethyl)-, 2-[[(1,1dimethylethoxy)carbonyl]oxy]ethyl ester (9CI) (CA INDEX NAME)

RN 473714-02-2 CAPLUS

CN β-Alanine, N,N-bis(2-methoxyethyl)-, 2-(2-methoxy-2-oxoethoxy)ethyl
ester (9CI) (CA INDEX NAME)

RN 473714-25-9 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, 1,3-dioxolan-4-ylmethyl ester (9CI) (CA INDEX NAME)

L8 ANSWER 3 OF 4 CAPLUS COPYRIGHT 2004 ACS on STN

AN 2002:638186 CAPLUS

DN 137:192762

TI Amine compounds, resist compositions and patterning process

IN Hatakeyama, Jun; Kobayashi, Tomohiro; Watanabe, Takeru

PA Shin-Etsu Chemical Co., Ltd., Japan

SO U.S. Pat. Appl. Publ., 40 pp. CODEN: USXXCO

DT Patent

LA English

FAN.CNT 1

TIM COUL I								
		PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
	ΡI	US 2002115018	A1	20020822	US 2001-3288	20011206		
		US 6743564	B2	20040601				
		JP 2002249478	A2	20020906	JP 2001-369719	20011204		
	PRAI	JP 2000-373316	Α	20001207				
	os	MARPAT 137:192762						

AB Amine compds. having a cyano group are useful in resist compns. for preventing a resist film from thinning and also for enhancing the resolution and focus margin of resist. The invention amine compds. have general formulas: (R2)b-N-(R1-CN)a; I; (R2)b-N-(R1C(=0)OR4-CN)a; II (R1,4 = C1-4 alkylene; R2 = C1-20 cycloc alkyl which may contain a hydroxy group, ether, carbonyl, ester, lactone ring, carbonate, cyano group; R3 = C2-20 alkylene which may contain hydroxy, ether, thioether, carbonyl, ester, thioester group, carbonate; a = 1-3; a+b = 3).

IT 449165-74-6P 449165-79-1P

RL: PRP (Properties); SPN (Synthetic preparation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (amine compds. and **photoresist** compns. for patterning process)

RN 449165-74-6 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-cyanoethyl ester (9CI) (CA INDEX NAME)

RN 449165-79-1 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, 2-cyanoethyl ester (9CI) (CA INDEX NAME)

IT 449165-61-1P 449165-71-3P

RL: RCT (Reactant); SPN (Synthetic preparation); TEM (Technical or engineered material use); PREP (Preparation); RACT (Reactant or reagent); USES (Uses)

(amine compds. and ${\tt photoresist}$ compns. for patterning process)

RN 449165-61-1 CAPLUS

CN β -Alanine, N,N-bis(2-hydroxyethyl)-, cyanomethyl ester (9CI) (CA INDEX NAME)

RN 449165-71-3 CAPLUS

CN β -Alanine, N,N-bis(2-hydroxyethyl)-, 2-cyanoethyl ester (9CI) (CA INDEX NAME)

IT 449165-62-2P 449165-63-3P 449165-66-6P 449165-67-7P 449165-77-9P 449165-81-5P

RL: SPN (Synthetic preparation); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(amine compds. and **photoresist** compns. for patterning process)

RN 449165-62-2 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, cyanomethyl ester (9CI) (CA INDEX NAME)

RN 449165-63-3 CAPLUS

CN β-Alanine, N,N-bis[2-(formyloxy)ethyl]-, cyanomethyl ester (9CI) (CI INDEX NAME)

RN 449165-66-6 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, cyanomethyl ester (9CI) (CA INDEX NAME)

RN 449165-67-7 CAPLUS

CN β -Alanine, N,N-bis[2-(methoxymethoxy)ethyl]-, cyanomethyl ester (9CI) (CA INDEX NAME)

RN 449165-77-9 CAPLUS

CN β -Alanine, N,N-bis[2-(formyloxy)ethyl]-, 2-cyanoethyl ester (9CI) (CA INDEX NAME)

RN 449165-81-5 CAPLUS

CN β -Alanine, N,N-bis[2-(methoxymethoxy)ethyl]-, 2-cyanoethyl ester (9CI) (CA INDEX NAME)

L8 ANSWER 4 OF 4 CAPLUS COPYRIGHT 2004 ACS on STN

AN 2001:523645 CAPLUS

DN 135:129564

TI Chemically amplified resist composition containing amine derivative having carbonyl group, ester group, or carbonate group

IN Hatakeyama, Jun; Osawa, Yoichi; Watanabe, Takeshi

PA Shin-Etsu Chemical Industry Co., Ltd., Japan

SO Jpn. Kokai Tokkyo Koho, 37 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

PAN.CNI I									
	PATENT NO.		DATE	APPLICATION NO.	DATE				
ΡI	JP 2001194776	A2	20010719	JP 2000-328131	20001027				
	US 6673511	B1	20040106	US 2000-697921	20001027				
	US 2004106063	A1	20040603	US 2003-615683	20030709				
PRAI	JP 1999-308496	Α	19991029						

parent

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os
     MARPAT 135:129564
AB
     The chemical amplified resist composition contains amine compound N(X)n(Y)3-n
(n =
     1-3, integer; X = -R1-O-R2-, -R1-C(=O)-O-R61; R1 = C1-5 alkylene; R2 = -R1-O-R2-
     C1-20 alkyl containing carbonyl or ester group; R61 = carbonyl, ester, ether,
     etc.; Y = H, C1-20 alkyl). The composition, which contains the aforementioned
     amine having carbonyl group, ester group, or carbonate group, generates
     little post exposure delay (PED) problem and provides the good acid
     diffusion control.
     58285-88-4
     RL: RCT (Reactant); RACT (Reactant or reagent)
         (chemical amplified resist composition containing amine having carbonyl
group,
         ester group, or carbonate group)
RN
     58285-88-4 CAPLUS
CN
     β-Alanine, N,N-bis(2-hydroxyethyl)-, ethyl ester (9CI) (CA INDEX
           СH<sub>2</sub>— СН<sub>2</sub>— ОН
EtO-C-CH2-CH2-N-CH2-CH2-OH
IT
     117789-12-5P 118480-08-3P 350684-62-7P
     350684-64-9P 350684-66-1P 350684-68-3P
     350684-69-4P 350684-70-7P 350684-71-8P
     350684-72-9P 350684-73-0P 350684-74-1P
     350684-75-2P 350684-78-5P 350684-79-6P
     350684-80-9P 350684-81-0P
     RL: SPN (Synthetic preparation); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
         (chemical amplified resist composition containing amine having carbonyl
group,
        ester group, or carbonate group)
RN
     117789-12-5 CAPLUS
CN
     \beta-Alanine, N,N-bis[2-(acetyloxy)ethyl]-, methyl ester (9CI) (CA
     INDEX NAME)
     Aco-CH_2-CH_2
ACO-CH2-CH2-N-CH2-CH2-C-OMe
     118480-08-3 CAPLUS
RN
CN
     β-Alanine, N,N-bis(2-hydroxyethyl)-, methyl ester (9CI) (CA INDEX
     NAME)
                 СH<sub>2</sub>-- СH<sub>2</sub>-- ОН
MeO-C-CH2-CH2-N-CH2-CH2-OH
     350684-62-7 CAPLUS
RN
CN
     β-Alanine, N, N-bis[2-(acetyloxy)ethyl]-, ethyl ester (9CI) (CA INDEX
     NAME)
    Aco-CH<sub>2</sub>-CH<sub>2</sub>
```

A3

US 2000-697921

ACO CH2-CH2-N-CH2-CH2-C-OEt

20001027

RN 350684-64-9 CAPLUS

CN β -Alanine, N,N-bis(2-hydroxyethyl)-, 2-methoxyethyl ester (9CI) (CA INDEX NAME)

RN 350684-66-1 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-methoxyethyl ester (9CI) (CA INDEX NAME)

RN 350684-68-3 CAPLUS

CN β -Alanine, N,N-bis(2-hydroxyethyl)-, 2-hydroxyethyl ester (9CI) (CA INDEX NAME)

RN 350684-69-4 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-(acetyloxy)ethyl ester (9CI) (CA INDEX NAME)

RN 350684-70-7 CAPLUS

CN β-Alanine, N,N-bis(2-hydroxyethyl)-, 2-methoxy-2-oxoethyl ester (9CI) (CA INDEX NAME)

RN 350684-71-8 CAPLUS

CN β-Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-methoxy-2-oxoethyl ester
(9CI) (CA INDEX NAME)

RN 350684-72-9 CAPLUS

CN β-Alanine, N,N-bis(2-hydroxyethyl)-, 2-oxopropyl ester (9CI) (CA INDEX NAME)

RN 350684-73-0 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, 2-oxopropyl ester (9CI) (CA INDEX NAME)

RN 350684-74-1 CAPLUS

CN β -Alanine, N,N-bis(2-hydroxyethyl)-, (tetrahydro-2-furanyl)methyl ester (9CI) (CA INDEX NAME)

RN 350684-75-2 CAPLUS

CN β -Alanine, N,N-bis[2-(acetyloxy)ethyl]-, (tetrahydro-2-furanyl)methyl ester (9CI) (CA INDEX NAME)

RN 350684-78-5 CAPLUS

CN β -Alanine, N,N-bis(2-hydroxyethyl)-, 4-hydroxybutyl ester (9CI) (CA INDEX NAME)

о
$$_{\rm CH_2-CH_2-OH}$$
 но- $_{\rm (CH_2)_4-O-C-CH_2-CH_2-N-CH_2-CH_2-OH}$

RN 350684-79-6 CAPLUS

CN β -Alanine, N,N-bis[2-(formyloxy)ethyl]-, 4-(formyloxy)butyl ester (9CI) (CA INDEX NAME)

о с
$${\rm H_2-CH_2-o-CHo}$$
 онс ${\rm -o-(CH_2)_4-o-C-CH_2-CH_2-N-CH_2-CH_2-o-CHo}$

RN 350684-80-9 CAPLUS

CN β -Alanine, N,N-bis[2-(formyloxy)ethyl]-, 2-(formyloxy)ethyl ester (9CI) (CA INDEX NAME)

о сн
$$_2$$
 - сн $_2$ - о - сно онс- о - сн $_2$ - сн $_2$ - о - сн $_2$ - сн $_2$ - о - сно

RN 350684-81-0 CAPLUS

CN β -Alanine, N,N-bis(2-methoxyethyl)-, methyl ester (9CI) (CA INDEX NAME)

=>

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2002:831831 CAPLUS
AN
DN
    137:325160
TI
    Preparation of novel tertiary amine compounds having an ester structure as
    additives for chemical amplification resists
    Watanabe, Takeru; Hasegawa, Koji; Kinsho, Takeshi; Hatakeyama, Jun
IN
    Shin-Etsu Chemical Co., Ltd., Japan
PA
SO
    Eur. Pat. Appl., 31 pp.
    CODEN: EPXXDW
DT
    Patent
    English
LA
FAN.CNT 1
    PATENT NO.
                   KIND DATE
                                      APPLICATION NO. DATE
    -----
                                       ______
    EP 1253138 A2 20021030
EP 1253138 A3 20030924
                                      EP 2002-252827 20020423
PΙ
        R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
            IE, SI, LT, LV, FI, RO, MK, CY, AL, TR
                                  US 2002-127120
    US 2002193622 A1 20021219
                                                        20020422
    JP 2003012621
                          20030115
                                       JP 2002-120468 20020423
                     A2
PRAI JP 2001-123927
                          20010423
                     Α
    MARPAT 137:325160
L9
    ANSWER 2 OF 2 CAPLUS COPYRIGHT 2004 ACS on STN
    2001:523645 CAPLUS
AN
DN
TI
    Chemically amplified resist composition containing
    amine derivative having carbonyl group, ester group, or carbonate group
IN
    Hatakeyama, Jun; Osawa, Yoichi; Watanabe, Takeshi
PA
    Shin-Etsu Chemical Industry Co., Ltd., Japan
SO
    Jpn. Kokai Tokkyo Koho, 37 pp.
    CODEN: JKXXAF
DT
    Patent
LΑ
    Japanese
FAN.CNT 1
    PATENT NO.
                    KIND DATE
                                      APPLICATION NO. DATE
    -----
                   ----
                                       ______
PΙ
    JP 2001194776
                   A2 20010719
                                      JP 2000-328131 20001027
    US 6673511
                    B1 20040106
                                       US 2000-697921
                                                       20001027
    US 2004106063
                    A1 20040603
                                       US 2003-615683 20030709
PRAI JP 1999-308496 A 19991029
US 2000-697921 A3 20001027
                         19991029
os
    MARPAT 135:129564
```

ANSWER 1 OF 2 CAPLUS COPYRIGHT 2004 ACS on STN

L9

```
AN
     2002:831831 CAPLUS
DN
     137:325160
     Preparation of novel tertiary amine compounds having an ester structure as
TI
     additives for chemical amplification resists
     Watanabe, Takeru; Hasegawa, Koji; Kinsho, Takeshi; Hatakeyama, Jun
PA
     Shin-Etsu Chemical Co., Ltd., Japan
SO
     Eur. Pat. Appl., 31 pp.
     CODEN: EPXXDW
DT
     Patent
LA
     English
FAN.CNT 1
     PATENT NO.
                      KIND DATE
                                           APPLICATION NO. DATE
     -----
                      ----
                                            -----
PΙ
     EP 1253138
                      A2
                            20021030
                                            EP 2002-252827
                                                             20020423
     EP 1253138
                      A3
                            20030924
         R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
             IE, SI, LT, LV, FI, RO, MK, CY, AL, TR
                       A1
                            20021219
                                           US 2002-127120
                                                             20020422
     JP 2003012621
                       A2
                            20030115
                                            JP 2002-120468
                                                             20020423
PRAI JP 2001-123927
                             20010423
os
     MARPAT 137:325160
     The invention provides novel and useful ester group-containing tertiary amine
AB
     compds. (R1OCH2CH2) nN(CH2CH2CO2R2) 3-n [n is 1 or 2; R1, R2 = (cyclo)alky1
     groups which may contain an ether, carbonyl or carbonyloxy group] which,
     when used as additives in chemical amplification photolithog., can yield
     photoresists having a high resolution and an excellent focus margin. Thus, a
     mixture of 10.5 g each Et acrylate and diethanolamine was allowed to stand
     20 h at 20-30 °C, 25.6 g triethylamine, 100 mg 4-
     dimethylaminopyridine, 100 g THF, and 22.4 g of acetic anhydride were
     added and the mixture stirred for 10 h to afford 95 %
     (AcOCH2CH2) NCH2CH2CO2Et. The photoresists prepared by adding the ester
     group-containing tertiary amine compds. of the invention have a much wider
     focus margin, as compared with conventional photoresists.
IT
     350684-82-1P 350684-83-2P 350684-85-4P
     473714-03-3P 473714-04-4P 473714-05-5P
     473714-06-6P 473714-07-7P 473714-08-8P
     473714-09-9P 473714-10-2P 473714-11-3P
     473714-12-4P 473714-13-5P 473714-14-6P
     473714-15-7P 473714-16-8P 473714-17-9P
     473714-18-0P 473714-19-1P 473714-20-4P
     473714-21-5P 473714-22-6P 473714-23-7P
     473714-24-8P
     RL: MOA (Modifier or additive use); SPN (Synthetic preparation); PREP
     (Preparation); USES (Uses)
        (preparation of acrylate-(di)ethanolamine adducts as additives for chemical
        amplification resists)
RN
     350684-82-1 CAPLUS
CN
     \beta-Alanine, N-[2-(acetyloxy)ethyl]-N-(3-methoxy-3-oxopropyl)-, methyl
     ester (9CI) (CA INDEX NAME)
    O ACO-CH2-CH2
                            0
MeO-C-CH<sub>2</sub>-CH<sub>2</sub>-N-CH<sub>2</sub>-CH<sub>2</sub>-C-OMe
RN
     350684-83-2 CAPLUS
CN
     \beta-Alanine, N-[2-(acetyloxy)ethyl]-N-(3-ethoxy-3-oxopropyl)-, ethyl
     ester (9CI) (CA INDEX NAME)
```

ANSWER 1 OF 2 CAPLUS COPYRIGHT 2004 ACS on STN

$$\begin{array}{c|c} \text{O} & \text{AcO-CH}_2\text{--}\text{CH}_2 & \text{O} \\ \parallel & \parallel & \parallel \\ \text{EtO-C-CH}_2\text{--}\text{CH}_2\text{--}\text{N--CH}_2\text{--}\text{CH}_2\text{--}\text{C--OEt} \end{array}$$

RN 350684-85-4 CAPLUS

CN β -Alanine, N-(2-methoxyethyl)-N-(3-methoxy-3-oxopropyl)-, methyl ester (9CI) (CA INDEX NAME)

RN 473714-03-3 CAPLUS

CN β -Alanine, N-[2-(acetyloxy)ethyl]-N-(3-oxo-3-propoxypropyl)-, propyl ester (9CI) (CA INDEX NAME)

RN 473714-04-4 CAPLUS

CN β -Alanine, N-[2-(acetyloxy)ethyl]-N-[3-(2-methoxyethoxy)-3-oxopropyl]-, 2-methoxyethyl ester (9CI) (CA INDEX NAME)

RN 473714-05-5 CAPLUS

CN β -Alanine, N-[3-[2-(acetyloxy)ethoxy]-3-oxopropyl]-N-[2-(acetyloxy)ethyl]-, 2-(acetyloxy)ethyl ester (9CI) (CA INDEX NAME)

RN 473714-06-6 CAPLUS

CN β -Alanine, N-[2-[[(acetyloxy)acetyl]oxy]ethyl]-N-(3-methoxy-3-oxopropyl)-, methyl ester (9CI) (CA INDEX NAME)

RN 473714-07-7 CAPLUS

CN β -Alanine, N-[2-[[(acetyloxy)acetyl]oxy]ethyl]-N-(3-ethoxy-3-oxopropyl)-, ethyl ester (9CI) (CA INDEX NAME)

RN 473714-08-8 CAPLUS

CN β -Alanine, N-[2-[(methoxyacetyl)oxy]ethyl]-N-(3-methoxy-3-oxopropyl)-, methyl ester (9CI) (CA INDEX NAME)

RN 473714-09-9 CAPLUS

CN β-Alanine, N-(3-ethoxy-3-oxopropyl)-N-[2-[(methoxyacetyl)oxy]ethyl]-, ethyl ester (9CI) (CA INDEX NAME)

RN 473714-10-2 CAPLUS

CN β -Alanine, N-[2-[[(1,1-dimethylethoxy)carbonyl]oxy]ethyl]-N-(3-methoxy-3-oxopropyl)-, methyl ester (9CI) (CA INDEX NAME)

RN 473714-11-3 CAPLUS

CN β -Alanine, N-[2-[[(1,1-dimethylethoxy)carbonyl]oxy]ethyl]-N-(3-ethoxy-3-oxopropyl)-, ethyl ester (9CI) (CA INDEX NAME)

RN 473714-12-4 CAPLUS

CN β -Alanine, N-(3-methoxy-3-oxopropyl)-N-[2-(1-oxopropoxy)ethyl]-, methyl ester (9CI) (CA INDEX NAME)

RN 473714-13-5 CAPLUS

CN β -Alanine, N-(3-ethoxy-3-oxopropyl)-N-[2-(1-oxopropoxy)ethyl]-, ethyl ester (9CI) (CA INDEX NAME)

RN 473714-14-6 CAPLUS

CN β -Alanine, N-[2-(formyloxy)ethyl]-N-(3-methoxy-3-oxopropyl)-, methyl ester (9CI) (CA INDEX NAME)

RN 473714-15-7 CAPLUS

CN β -Alanine, N-(3-ethoxy-3-oxopropyl)-N-[2-(formyloxy)ethyl]-, ethyl ester (9CI) (CA INDEX NAME)

$$\begin{array}{c|c} \text{O} & \text{CH}_2-\text{CH}_2-\text{O}-\text{CHO} \\ \parallel & \parallel & \parallel \\ \text{EtO}-\text{C}-\text{CH}_2-\text{CH}_2-\text{CH}_2-\text{CH}_2-\text{CH}_2-\text{C}-\text{OEt} \\ \parallel & \parallel & \parallel \\ \text{O} \end{array}$$

RN 473714-16-8 CAPLUS

CN β-Alanine, N-[2-(2,2-dimethyl-1-oxopropoxy)ethyl]-N-(3-methoxy-3-oxopropyl)-, methyl ester (9CI) (CA INDEX NAME)

RN 473714-17-9 CAPLUS

CN β -Alanine, N-[2-(2,2-dimethyl-1-oxopropoxy)ethyl]-N-(3-ethoxy-3-oxopropyl)-, ethyl ester (9CI) (CA INDEX NAME)

RN 473714-18-0 CAPLUS

CN β -Alanine, N-(3-ethoxy-3-oxopropyl)-N-(2-methoxyethyl)-, ethyl ester (9CI) (CA INDEX NAME)

RN 473714-19-1 CAPLUS

CN β-Alanine, N-(2-methoxyethyl)-N-(3-oxo-3-propoxypropyl)-, propyl ester (9CI) (CA INDEX NAME)

RN 473714-20-4 CAPLUS

CN β -Alanine, N-[3-(2-methoxyethoxy)-3-oxopropyl]-N-(2-methoxyethyl)-, 2-methoxyethyl ester (9CI) (CA INDEX NAME)

RN 473714-21-5 CAPLUS

CN β -Alanine, N-[3-[2-(acetyloxy)ethoxy]-3-oxopropyl]-N-(2-methoxyethyl)-, 2-(acetyloxy)ethyl ester (9CI) (CA INDEX NAME)

RN 473714-22-6 CAPLUS

CN β -Alanine, N-(3-ethoxy-3-oxopropyl)-N-(2-methoxyethyl)-, methyl ester (9CI) (CA INDEX NAME)

```
RN
     473714-23-7 CAPLUS
     β-Alanine, N-[2-[2-(acetyloxy)ethoxy]ethyl]-N-(3-methoxy-3-oxopropyl)-
CN
     , methyl ester (9CI) (CA INDEX NAME)
RN
     473714-24-8 CAPLUS
CN
     \beta-Alanine, N-[2-[2-(formyloxy)ethoxy]ethyl]-N-(3-methoxy-3-oxopropyl)-
     , methyl ester (9CI) (CA INDEX NAME)
        СH<sub>2</sub>— СH<sub>2</sub>— О— СH<sub>2</sub>— СH<sub>2</sub>— О— СНО
ANSWER 2 OF 2 CAPLUS COPYRIGHT 2004 ACS on STN
L9
     2001:523645 CAPLUS
AN
     135:129564
DN
     Chemically amplified resist composition containing
TI
     amine derivative having carbonyl group, ester group, or carbonate group
IN
     Hatakeyama, Jun; Osawa, Yoichi; Watanabe, Takeshi
     Shin-Etsu Chemical Industry Co., Ltd., Japan
PA
     Jpn. Kokai Tokkyo Koho, 37 pp.
SO
     CODEN: JKXXAF
DT
     Patent
LA
     Japanese
FAN.CNT 1
     PATENT NO.
                     KIND DATE
                                        APPLICATION NO. DATE
     ------
                    ----
    JP 2001194776
PΙ
                    A2 20010719
                                         JP 2000-328131
                                                          20001027
    US 6673511
                     B1 20040106
                                         US 2000-697921
                                                          20001027
    US 2004106063
                     A1 20040603
                                         US 2003-615683
                                                          20030709
PRAI JP 1999-308496
                    Δ
                           19991029
     US 2000-697921
                     A3 '20001027
OS
    MARPAT 135:129564
AB
    The chemical amplified resist composition contains amine compound N(X)n(Y)3-n
(n =
     1-3, integer; X = -R1-O-R2-, -R1-C(=0)-O-R61; R1 = C1-5 alkylene; R2 = -R1-C
     C1-20 alkyl containing carbonyl or ester group; R61 = carbonyl, ester, ether,
     etc.; Y = H, C1-20 alkyl). The composition, which contains the aforementioned
     amine having carbonyl group, ester group, or carbonate group, generates
     little post exposure delay (PED) problem and provides the good acid
     diffusion control.
IT
    85997-58-6P 87278-81-7P 144576-44-3P
     350684-82-1P 350684-83-2P 350684-84-3P
    350684-85-4P
    RL: SPN (Synthetic preparation); TEM (Technical or engineered material
    use); PREP (Preparation); USES (Uses)
        (chemical amplified resist composition containing amine having carbonyl
group,
       ester group, or carbonate group)
    85997-58-6 CAPLUS
RN
CN
    \beta-Alanine, N-(2-hydroxyethyl)-N-(3-methoxy-3-oxopropyl)-, methyl
    ester (9CI) (CA INDEX NAME)
```

RN 87278-81-7 CAPLUS

CN β-Alanine, N-(3-ethoxy-3-oxopropyl)-N-(2-hydroxyethyl)-, ethyl ester (9CI) (CA INDEX NAME)

$$\begin{array}{c|c} \text{O} & \text{HO-CH}_2\text{--CH}_2 & \text{O} \\ || & | & || \\ \text{Eto-C-CH}_2\text{--CH}_2\text{--N-CH}_2\text{--CH}_2\text{--C-OEt} \end{array}$$

RN 144576-44-3 CAPLUS

CN β-Alanine, N-(3-hydroxypropyl)-N-(3-methoxy-3-oxopropyl)-, methyl ester (9CI) (CA INDEX NAME)

RN 350684-82-1 CAPLUS

CN β -Alanine, N-[2-(acetyloxy)ethyl]-N-(3-methoxy-3-oxopropyl)-, methyl ester (9CI) (CA INDEX NAME)

RN 350684-83-2 CAPLUS

CN β-Alanine, N-[2-(acetyloxy)ethyl]-N-(3-ethoxy-3-oxopropyl)-, ethyl ester (9CI) (CA INDEX NAME)

RN 350684-84-3 CAPLUS

CN β-Alanine, N-[3-(acetyloxy)propyl]-N-(3-methoxy-3-oxopropyl)-, methyl ester (9CI) (CA INDEX NAME)

RN 350684-85-4 CAPLUS

CN β-Alanine, N-(2-methoxyethyl)-N-(3-methoxy-3-oxopropyl)-, methyl ester (9CI) (CA INDEX NAME)

=>